

# Citations for Target : HgCdTe

Pub. Year	Authors, Title, Journal Citation and Comments	Citation Numb
1988	Wilson, R. G. <b>'(111) Random and (110) Channeling Implantation Profiles and Range Parameters in HgCdTe'</b> <i>J. Appl. Phys., 63, 5302-5311 (1988)</i> <i>Comment : R, dR. 45 Ions (H to Ta) at 100-700 keV -&gt; HgCdTe</i>	1988-Wils 1397
1988	Wilson, R. G. <b>'Ion Implantation and SIMS Profiling of Impurities in II-VI Materials HgCdTe and CdTe'</b> <i>J. Crystal Growth, 86, 735-743 (1988)</i> <i>Comment : R, dR. 52 Ions (H-Hg) at 100-700 keV -&gt; CdTe, HgCdTe</i>	1988-Wils2 1445